Methylamine-Gas-Induced Defect-Healing Behavior of CH₃NH₃PbI₃ Thin Films for Perovskite Solar Cells**

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Abstract: We report herein the discovery of methylamine (CH₃NH₃) induced defect-healing (MIDH) of CH₃NH₃PbI₃ perovskite thin films based on their ultrafast (seconds), reversible chemical reaction with CH₃NH₃ gas at room temperature. The key to this healing behavior is the formation and spreading of an intermediate CH₃NH₃PbI₃·xCH₃NH₃ liquid phase during this unusual perovskite–gas interaction. We demonstrate the versatility and scalability of the MIDH process, and show dramatic enhancement in the performance of perovskite solar cells (PSCs) with MIDH. This study represents a new direction in the formation of defect-free films of hybrid perovskites.

The field of photovoltaics is undergoing a revolution with the introduction of solution-processed CH₃NH₃PbI₃ (MAPbI₃) perovskite thin films as light absorbers[1–4]. The ability to form high-quality perovskite thin films over large areas is critical to the research and development in this area. Thus, tremendous effort is being directed towards gaining better control over the crystallization of the perovskite from solutions,[5] which has resulted in the development of a variety of new methods.[6,7] However, solution-processes tend to be less robust, and they require exacting processing conditions. Thus, solution-processed perovskite films invariably contain defects, such as voids and pinholes. In this context, post-processing morphology-reconstruction of defective films is a more attractive approach for the formation of high-quality, large-scale perovskite films, yet there is a dearth of effort in this area. In this study, we report the discovery of room-temperature, ultrastable methylamine-induced defect-healing (MIDH) of defective MAPbI₃ perovskite films. Central to this unprecedented healing behavior is the unusual chemical interaction between MAPbI₃ perovskite and methylamine (CH₃NH₃) gas (Figure 1).

Figure 1A shows two large, faceted MAPbI₃ perovskite particles (ca. 2 mm) in contact with each other. In Figure 1B, CH₃NH₃ gas is introduced, resulting in the smoothening of the crystal edges within 1 min. After 10 min, a pool of clear liquid is observed (Figure 1C), and the surface of MAPbI₃ perovskite crystals appear to “melt”. In 120 min, the full collapse of MAPbI₃ perovskite crystals into the liquid is complete (Figure 1D). The liquid state of the “melted” crystals is confirmed by naked eye, as shown in Figure S1. At this point, the CH₃NH₃ gas is removed, and within 2 min, the MAPbI₃ perovskite begins to recrystallize, along with the darkening of the liquid (Figure 1E). After 120 min, the crystallization of MAPbI₃ perovskite is complete (Figure 1F) and the final fused MAPbI₃ perovskite particle has contracted compared with the liquid (Figure 1D). This solid–liquid conversion process is reversible, where the MAPbI₃ perovskite converts into a clear liquid again when CH₃NH₃ gas is reintroduced, and converts back to MAPbI₃ perovskite upon CH₃NH₃ degassing.

This conversion of solid MAPbI₃ perovskite into liquid is clearly the result of uptake of CH₃NH₃ molecules. It has been reported that the basic N atom with an electron lone pair in
alkylamine molecules interacts with the PbI$_3$-octahedra in the layered PbI$_3$ structure.\textsuperscript{[5]} It is highly likely that CH$_3$NH$_2$ reacts in a similar way with the inorganic PbI$_3$-octahedra framework in MAPbI$_3$ perovskite, resulting in the complete collapse [Eq. (1)] of that structure into a liquid. Upon reduction of CH$_3$NH$_2$ gas partial pressure, CH$_3$NH$_2$ molecules are released from the liquid [Eq. (2)], resulting in the reconstruction of the MAPbI$_3$ perovskite structure. The commonality of the methyl group in MAPbI$_3$ and CH$_3$NH$_2$ gas appears to be responsible for the complete conversion and reversibility.

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\text{CH}_3\text{NH}_2\text{PbI}_3(s) + x \text{CH}_3\text{NH}_2(g) \rightarrow \text{CH}_3\text{NH}_2\text{PbI}_3 \cdot x \text{CH}_3\text{NH}_2(l)
\]

\[
\text{CH}_3\text{NH}_2\text{PbI}_3 \cdot x \text{CH}_3\text{NH}_2(l) \rightarrow \text{CH}_3\text{NH}_2\text{PbI}_3(s) + x \text{CH}_3\text{NH}_2(g)
\]

To gain further insight into this gas–perovskite interaction behavior, the effect of the type of amine gas is studied, and the results are shown in Figure S2 in the Supporting Information. When ammonia (NH$_3$) gas, instead of CH$_3$NH$_2$, is introduced, the intercalation of NH$_3$ into the crystalline structure of the MAPbI$_3$ perovskite results in photo-bleaching (Figure S2A), similar to what has been reported earlier in the context of thin films.\textsuperscript{[9]} However, the NH$_3$–perovskite interaction does not result in the complete collapse of the solid into a liquid. This lack of collapse is most likely due to the lower basicity and the smaller size of NH$_3$ compared with CH$_3$NH$_2$. Thus, only minor morphology changes occur in the perovskite after the reversible interaction with NH$_3$ (Figure S2A). When larger-molecule amine gases, ethylamine (C$_2$H$_5$NH$_2$) or n-butylamine (C$_4$(CH$_3$)$_2$NH$_2$), are introduced, the MAPbI$_3$ perovskite particles appear to “melt” as well, resulting in the formation of liquid phase of MAPbI$_3$C$_2$H$_5$NH$_2$ or MAPbI$_3$C$_4$(CH$_3$)$_2$NH$_2$, respectively, accompanied by substantial volume expansion and surface smoothening (Figure S2B and Figure S2C). However, complete back-conversion into the black MAPbI$_3$ perovskite phase does not occur after the gas is removed. Thus, for alkyl group R other than CH$_3$, the reaction of CH$_3$NH$_2$ + R-NH$_2$ → R-NH$_3$I + CH$_3$NH$_2$ is likely to occur, resulting in the irreversible formation of a stable non-MAPbI$_3$ phase. These results highlight the importance of the rational selection of CH$_3$NH$_2$ gas for the MIDH of MAPbI$_3$ perovskite thin films.

Figure 2A shows how the phenomenon described above is applied to perform MIDH treatment of a porous, rough MAPbI$_3$ perovskite film, converting it into a fully dense, smooth film. In MIDH experiments, visually, the raw MAPbI$_3$ perovskite film appears translucent with a dull surface. At the instant of exposure to CH$_3$NH$_2$ gas, the film appears bleached, with the formation of the intermediate liquid-phase MAPbI$_3$C$_2$H$_5$NH$_2$. Upon removal from the CH$_3$NH$_2$-gas atmosphere, the film turns dark within 2–5 s, with a highly reflective (shiny) surface. The overall process occurs in an astonishingly short period of time, and results in the healing of the MAPbI$_3$ perovskite film from a defective state to a “perfect” state. (See Supporting Information for experimental details.) The transformation of the surface morphology of the MAPbI$_3$ perovskite film is clearly seen in the scanning electron microscope (SEM) and the atomic force microscope (AFM) images. Figure 2B is a SEM image of the raw MAPbI$_3$ perovskite film (ca. 250 nm thickness) prepared using the conventional one-step method. The growth of dendrite-like MAPbI$_3$ perovskite crystals, and voids between them is typical of one-step-processed perovskite films using dimethylformamide (DMF) solvent.\textsuperscript{[10]} The size of the voids in the starting raw film can reach up to several micrometers. After MIDH treatment, all the dendrite-like crystals and the voids have disappeared, and a dense, smooth MAPbI$_3$ perovskite film has emerged in its place (Figures 2C), which is responsible for the visual evolution of the film from dull to shiny. Figure 2D is an AFM topographical image of the raw MAPbI$_3$ perovskite film showing root mean square (RMS) roughness of approximately 153 nm over an 18 × 18 μm$^2$ area. In contrast, the AFM topographical image of the healed film in Figure 2E shows a remarkably dense and smooth film, with a RMS roughness of only around 6 nm.

Figure 3A shows X-ray diffraction (XRD) patterns of the raw MAPbI$_3$ perovskite film, MAPbI$_3$C$_2$H$_5$NH$_2$ intermediate film, and healed MAPbI$_3$ perovskite film on compact TiO$_2$-coated FTO glass substrates. The XRD pattern from the raw film confirms the typical MAPbI$_3$ perovskite phase. The XRD pattern of the MAPbI$_3$C$_2$H$_5$NH$_2$ intermediate film under CH$_3$NH$_2$ gas shows only substrate peaks, indicative of its non-crystalline nature. After CH$_3$NH$_2$ degassing, a phase-pure, 110-textured perovskite film evolves. Figure 3B shows the XRD intensity from the rough and the healed MAPbI$_3$ perovskite films for the 110 reflection under identical measurement conditions, showing a 15-fold increase in the counts after healing. This change is indicative of higher degree
of crystallinity and texture in the healed film, which is highly desirable for PSCs application.[11] Figure 3 C shows ultraviolet-visible (UV/Vis) optical absorption spectra. The raw film shows typical absorption of MAPbI$_3$ perovskite with an absorption edge at approximately 780 nm. The MAPbI$_3$·xCH$_3$NH$_2$ intermediate film shows almost no absorption, indicative of the collapse of the perovskite structure. The healed MAPbI$_3$ perovskite film recovers the absorption feature of the perovskite, but with significantly increased absorbance, especially in the 400–600 nm region. This is primarily due to the dense and uniform nature of the healed film, which prevents leakage of light through voids. Figure 3 D is a sequence of photoluminescence (PL) maps taken in situ during the MIDH process to complement the ex situ SEM, AFM, XRD, and UV/Vis studies. The non-uniform PL is consistent with the poor coverage in the raw MAPbI$_3$ perovskite film. The PL is completely quenched in the film immediately after the CH$_3$NH$_2$ gas is introduced, further confirming the absence of luminescing crystalline perovskite. Upon CH$_3$NH$_2$ degassing, the weak PL signal gradually recovers from localized areas, which indicates the nucleation of MAPbI$_3$ perovskite. Finally, uniform, stronger PL signal is observed over the entire area in the healed MAPbI$_3$ perovskite film.

We also demonstrate that the MIDH process is independent of the morphology of the starting films, where raw MAPbI$_3$ perovskite films with different types of common “defective” morphologies, deposited using a variety of solution-processing methods, can be healed to nearly the same “perfect” state using MIDH (Figures S3–S5). In particular, we show that commercial large-area (several cm$^2$) MAPbI$_3$ perovskite films deposited using the slot-die coating process can be fully healed using the MIDH process (Figure S6).

Based on all the results presented herein, the basic mechanisms involved in the MIDH of MAPbI$_3$ perovskite thin films are depicted schematically in Figure 4. Exposure to CH$_3$NH$_2$ gas results in the uptake of CH$_3$NH$_2$ molecules by the raw MAPbI$_3$ perovskite film accompanied by a volume expansion, collapse of the perovskite structure, and the formation of a clear liquid. This occurs in a very short time because of the nanoscale of the MAPbI$_3$ crystals in the thin films. The liquid spreads instantaneously owing to wetting of the substrate, and forms an ultra-smooth surface. In the case of mesoscopic-oxide layer on the substrate, the liquid is likely to infiltrate readily into the mesoporous structure. Upon removal of the CH$_3$NH$_2$-gas atmosphere, the liquid releases CH$_3$NH$_2$ molecules rapidly, once again, a result of the nanoscale of the liquid MAPbI$_3$·xCH$_3$NH$_2$ film. This release results in volume contraction, and rebuilding of the perovskite structure by rapid nucleation and growth, ultimately resulting in an ultra-smooth and dense MAPbI$_3$ thin film. Thus, the liquid state of the intermediate phase is critical to the healing process. This is further supported by the fact that the morphological defects of the raw MAPbI$_3$ films can also be healed using C$_2$H$_5$NH$_2$ or C$_2$(CH$_3$)$_2$NH$_3$ gases (Figure S7C–S7D), where a liquid intermediate phase forms (Figures S2B–S2C), but not NH$_3$ gas (Figure S7B), where the liquid intermediate phase is absent (Figure S2A). However, in the C$_2$H$_5$NH$_3$ or C$_2$(CH$_3$)$_2$NH$_3$ cases, the pure MAPbI$_3$ perovskite phase is not recovered, which is consistent with the in situ optical microscopy observations.

The effect of MIDH treatment on the performance of MAPbI$_3$-based PSCs is shown in Figure 5. Figure 5 A and 5 B are cross-sectional SEM images of the PSCs with raw and healed MAPbI$_3$ perovskite films, respectively. In the case of the healed film, the mesoporous TiO$_2$ layer is fully infiltrated with MAPbI$_3$ perovskite, and the dense MAPbI$_3$ perovskite...
“capping” layer shows smooth, uniform coverage (Figure 5B and Figure S8). The current-density (J)–voltage (V) responses in Figure 5C show obvious increase in all performance parameters (short circuit current $J_{sc}$: from 13.5 mA cm$^{-2}$ to 19.6 mA cm$^{-2}$; open circuit voltage $V_{oc}$: from 0.72 V to 1.08 V; fill factor FF: from 0.586 to 0.714) with MIDH treatment. A significant increase in the overall power conversion efficiency (PCE), from 5.7% to 15.1%, is observed, which clearly is the result of the improved film morphology. The $J_{sc}$ values are consistent with the external quantum efficiency (EQE) measurements presented in Figure S9. Since typical hysteresis (Figure S10) still exists in both PSCs, the maximum-power-point $J$, which is then converted into PCE, is monitored as shown in Figure 5D. The stabilizing PCE output at the maximum power point increases from 5.0% to 14.5%, further confirming the efficiency enhancement in PSCs with MIDH treatment. (PCEs statistics are presented in Figure S11.)

In summary, the room-temperature MIDH approach introduced herein provides an unprecedented capability for the processing of high-quality, uniform MAPbI$_3$ perovskite films over large-areas for high-performance PSCs and beyond. The ultrafast and facile nature of the MIDH process is compatible with established scalable thin-film processing technologies, as demonstrated in Figure S6. Furthermore, the concept of morphology-engineering based on reversible gas–solid interaction could be extended to a board range of organo-metal halide compounds. This approach opens a new direction in the formation of defect-free, large-area organo-metal halide materials.

**Experimental Section**

**MIDH Procedure:** The starting raw MAPbI$_3$ perovskite films were deposited using the conventional one-step method. A 40 wt% PbI$_2$-MAI (molar ratio 1:1) solution in N,N-dimethylformamide (DMF) was spin-coated (4000 rpm, 45 s) on compact TiO$_2$-coated FTO glass, followed by a heat-treatment at 100°C for 10 min. Subsequently, the raw MAPbI$_3$, perovskite films were simply placed in the CH$_3$NH$_3$ gas environment for 2–3 s at room temperature, and were then removed to the ambient quickly.

**Materials Characterization:** XRD patterns were obtained using an X-ray diffractometer (D8 Advance, Bruker, Germany) using Cu Kα radiation, with 0.02° step and 2 s/step dwell. UV/Vis absorbance spectra of the perovskite films were recorded using spectrometer (U-4100, Hitachi, Japan). UV/Vis measurements on the films under CH$_3$NH$_3$ gas were performed on samples sealed in quartz. A field-emission SEM (S-4800, Hitachi, Japan) was used to observe the top surfaces and cross-sections. AFM measurements were performed in contact mode using AFM microscope (S4000, Agilent, USA). In situ PL mapping was conducted using a confocal laser scanning microscope (Fluo ViewTM FV1000, Olympus, Japan). The in situ optical microscopy observation of two MAPbI$_3$ perovskite particles was carried out using a stereomicroscope (SZX16, Olympus, Japan).

**Solar Cell Fabrication and Performance Measurement:** The MAPbI$_3$ perovskite layer was then deposited on 250 nm thick mesoporous TiO$_2$ (on compact TiO$_2$-coated FTO glass) with or without the MIDH treatment as described above. The hole transporting material (HTM) was then deposited by spin-coating (3000 rpm, 30 s), followed by evaporation of 50 nm Ag layer to complete the solar cells. J–V characteristics of the as-fabricated PSCs were measured using a 2400 SourceMeter (Keithley, USA) under simulated one-sun AM 1.5G 100 mWcm$^{-2}$ intensity (Oriel Sol3A Class A, Newport, USA), under both reverse (from $V_{oc}$ to $J_{sc}$) and forward (from $J_{sc}$ to $V_{oc}$) scans. The maximum-power output stability of the PSCs was measured by monitoring the J output at the maximum-power V bias (deduced from the reverse-scan J–V curves). Typical active area of the PSCs is 0.09 cm$^2$ defined using non-reflective metal mask. External quantum efficiency (EQE) measurements were carried out on an EQE measurement setup (Newport, USA).

More detailed description of the experimental procedures, and additional results, are included in the supporting information.

**Keywords:** defect healing · methylamine · perovskite phases · photovoltaics · thin film

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